## CLAIMS

- 1. An organic thin-film transistor having an organic semiconductor layer, characterized in that the organic semiconductor layer comprises a fluorinated acene compound which is represented by a formula of  $C_{4n+2}F_{2n+4}$ , wherein n is an integer of 2 or greater.
- 2. An organic thin-film transistor comprising a gate electrode, a source electrode, a drain electrode, a gate insulating film, and an organic semiconductor layer, characterized in that the organic semiconductor layer comprises a fluorinated acene compound which is represented by a formula of  $C_{4n+2}F_{2n+4}$ , wherein n is an integer of 2 or greater.
- 3. The organic thin-film transistor as claimed in claim 1 or 2, characterized in that plural molecules of the fluorinated acene compound are oriented so that
  20 molecular axes of the molecules are approximately parallel to each other and a normal direction of a molecular plane of the molecule approximately corresponds to a direction of electric current flowing in the organic semiconductor layer.

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- 4. The organic thin-film transistor as claimed in any of claims 1 through 3, characterized in that the fluorinated acene compound is tetradecafluoropentacene.
- 5. The organic thin-film transistor as claimed in any of claims 1 through 3, characterized in that the fluorinated acene compound is dodecafluoronaphthacene.

6. A method of fabricating an organic thin-film transistor having a substrate and an organic semiconductor layer, characterized in that the organic semiconductor layer is formed by controlling temperature of the substrate to 30 °C or higher and 65 °C or lower and vacuum-depositing tetradecafluoropentacene on the substrate.

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- 7. A method of fabricating an organic thin-film transistor having a substrate and an organic semiconductor layer, characterized in that the organic semiconductor layer is formed by controlling temperature of the substrate to 24 °C or higher and 60 °C or lower and vacuum-depositing dodecafluoronaphthacene on the substrate.
- 8. An organic thin-film device characterized by comprising an organic thin-film transistor as claimed in any of claims 1 through 5.
- 9. The organic thin-film device as claimed in claim 8, characterized by comprising the organic thin-film transistor which constitutes an n-type thin-film transistor and a p-type thin-film transistor.
- 10. The organic thin-film device as claimed in claim 9, characterized in that the p-type thin-film transistor has an organic semiconductor layer which comprises pentacene.